

Low-temperature metallization & interconnection for silicon heterojunction & perovskite silicon tandem solar cells

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11th Metallization & Interconnection Workshop

Neuchâtel, Switzerland / hybrid

May 09, 2023

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Low-temperature processes

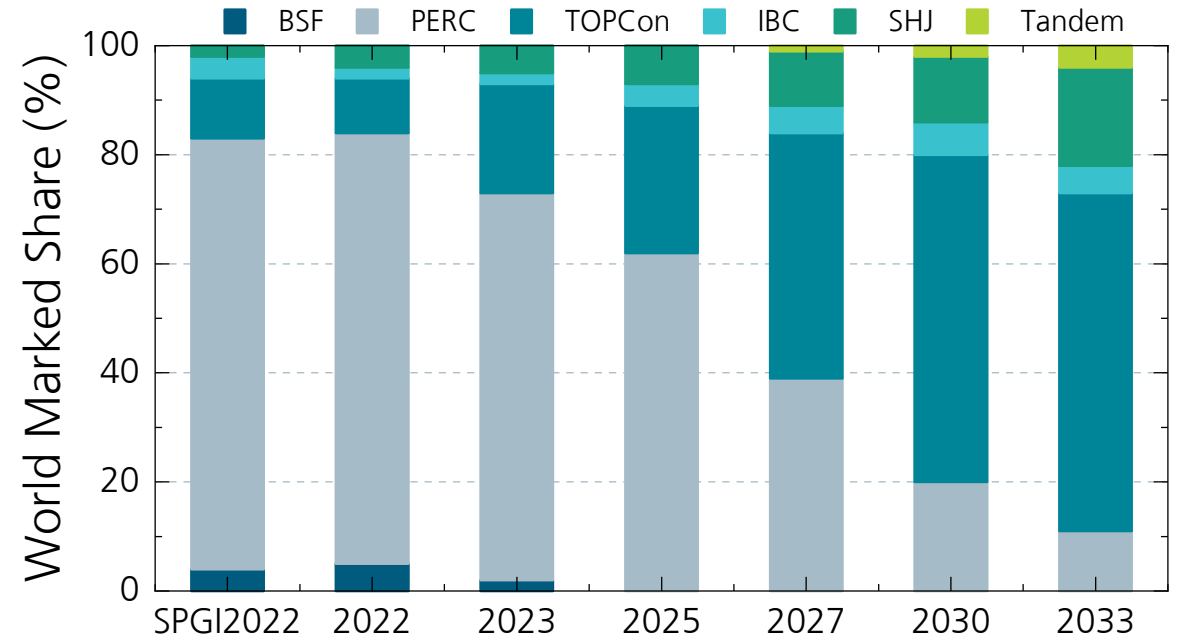
Motivation

Solar cell trend in PV industry

- PERC will be replaced by TOPCon
 - Record efficiency TOPCon: 26.1 % [1]
- IBC, SHJ and tandem only minor market share < 30 %

High-efficiency cell concepts

- Beside TOPCon, SHJ and perovskite Si tandem cells offer high photo conversion efficiencies
 - Record efficiency SHJ: 26.8 % [2]
 - Record efficiency Pero Si tandem: 33.2 % [3], on large wafer size: 26.8 % [4]
- But: Temperature-sensitive layers: a-Si, perovskite
- ➔ Low-temperature (LT) processing required



Taken from ITRPV 2023

What are the challenges for SHJ and tandem for LT metallization & LT interconnection?

[1] 26.1 % by JinkoSolar in October 2022

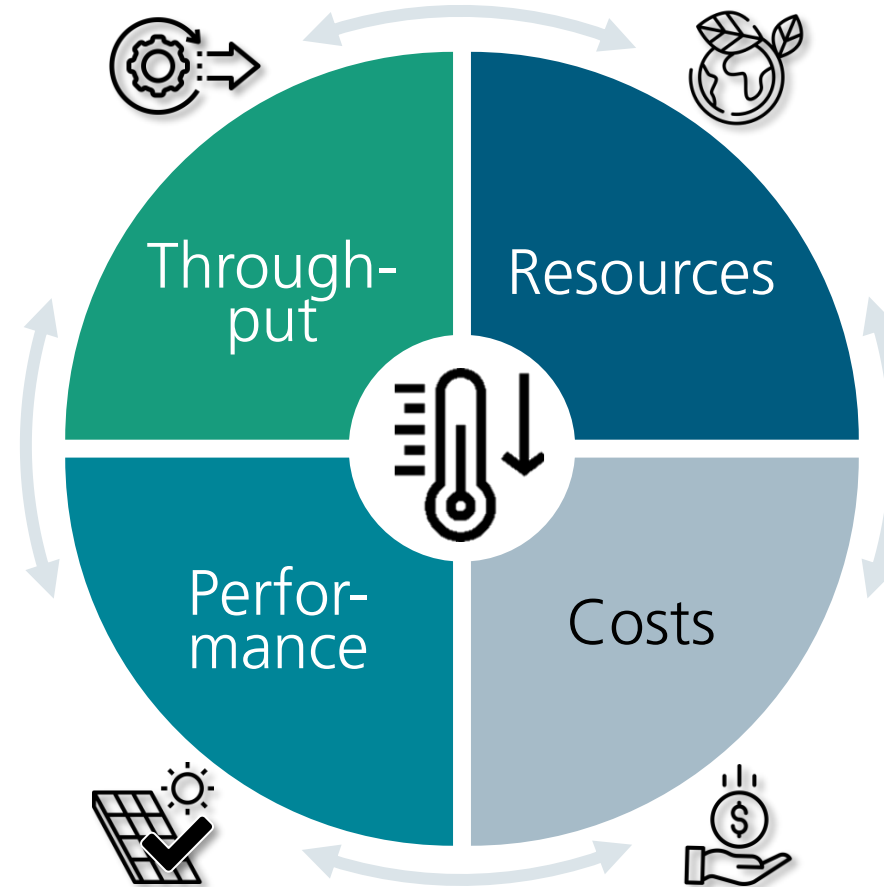
[2] 26.8 % by LONGI in November 2022

[3] 33.2 % by KAUST in April 2023

[4] 26.8 % by Oxford PV on large wafer of 274 cm² in November 2021

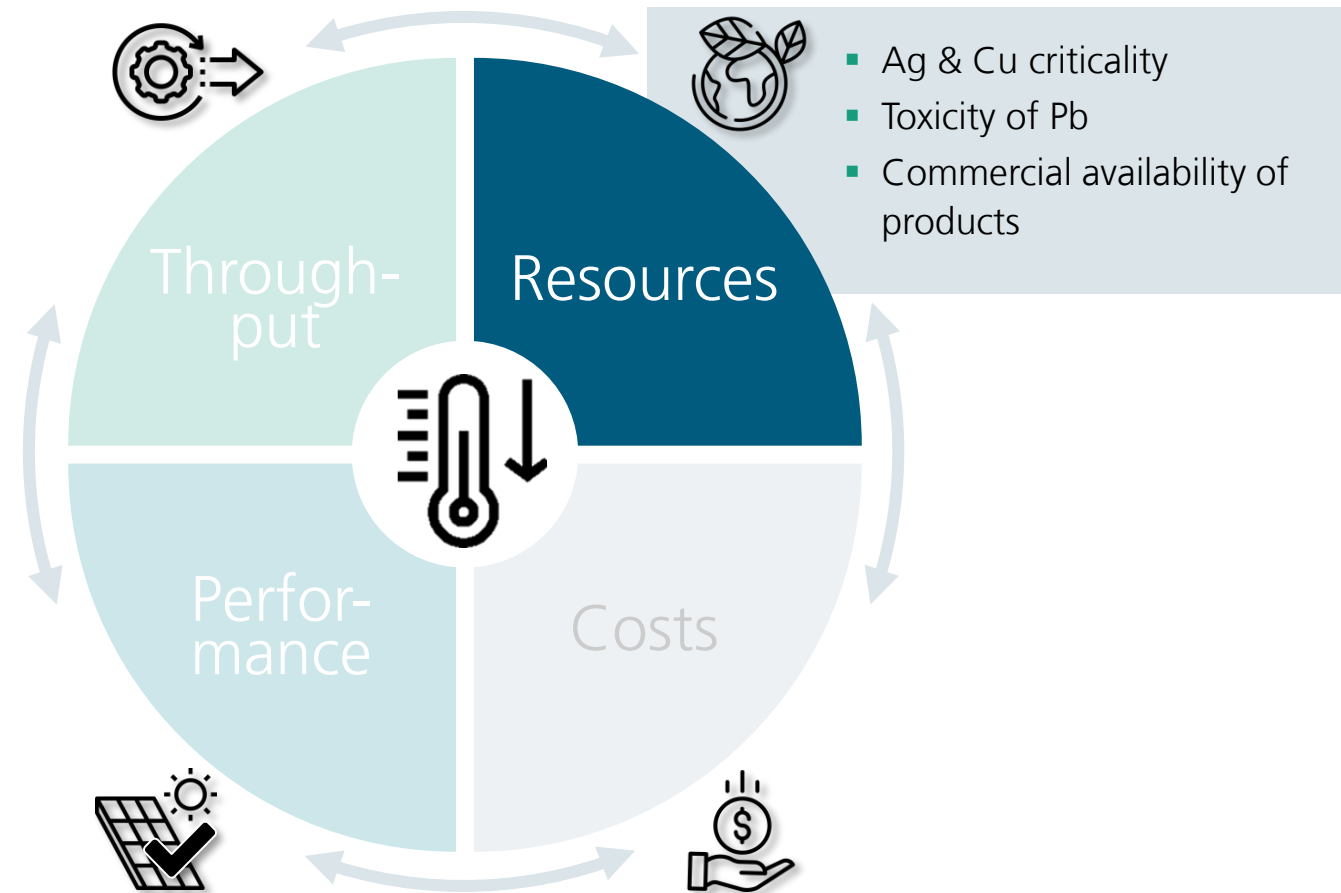
Low-temperature metallization & interconnection

Challenges for industrial application



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Resources for LT processes

Criticality, toxicity & availability



Critical resources in PV: Ag, In, Bi, Cu (Si, Ga, As, Cs) [1,3]

LT solder alloys

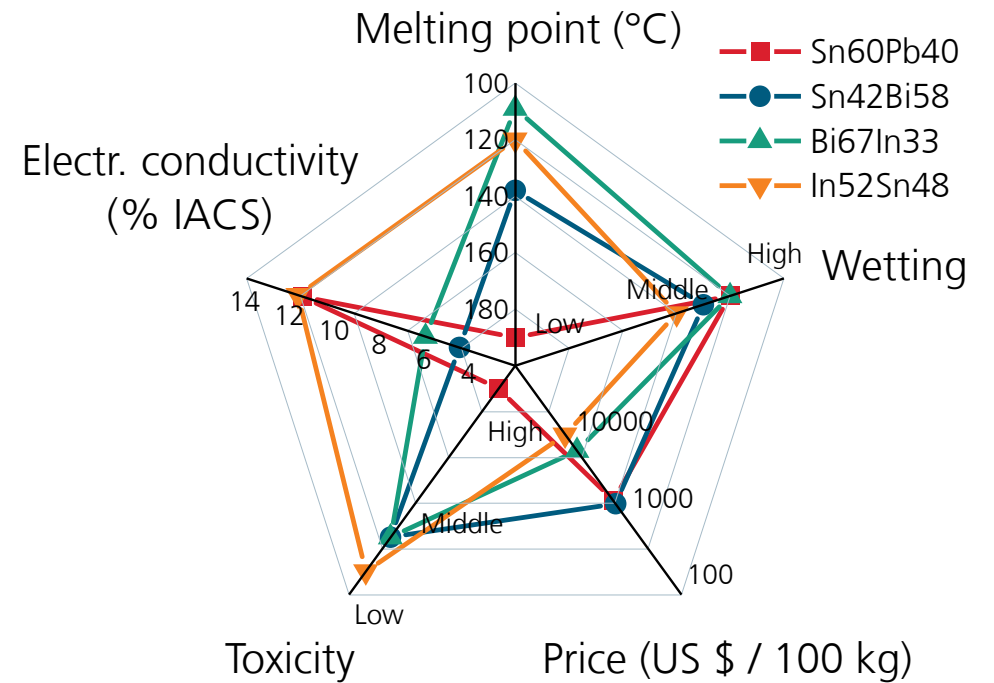
- **Ag-free** interconnection technology
- Substitution of toxic **Pb** is challenging [1,2,3]
- Low-melting alloys contain **Bi** & **In**
- Limited availability of LT solder-coated PV ribbons/wires

Electrically conductive adhesives (ECAs)

- Commercially available with wide processing window
- Mostly **Ag-based***, also **Cu-core/Ag-coated** versions

LT metallization pastes

- Various pastes commercially available, esp. from Japan
- Mostly **Ag-based****, also **Cu-core/Ag-coated** versions



Data taken from [4-7]
IACS = Intern. Annealed Cu Standard

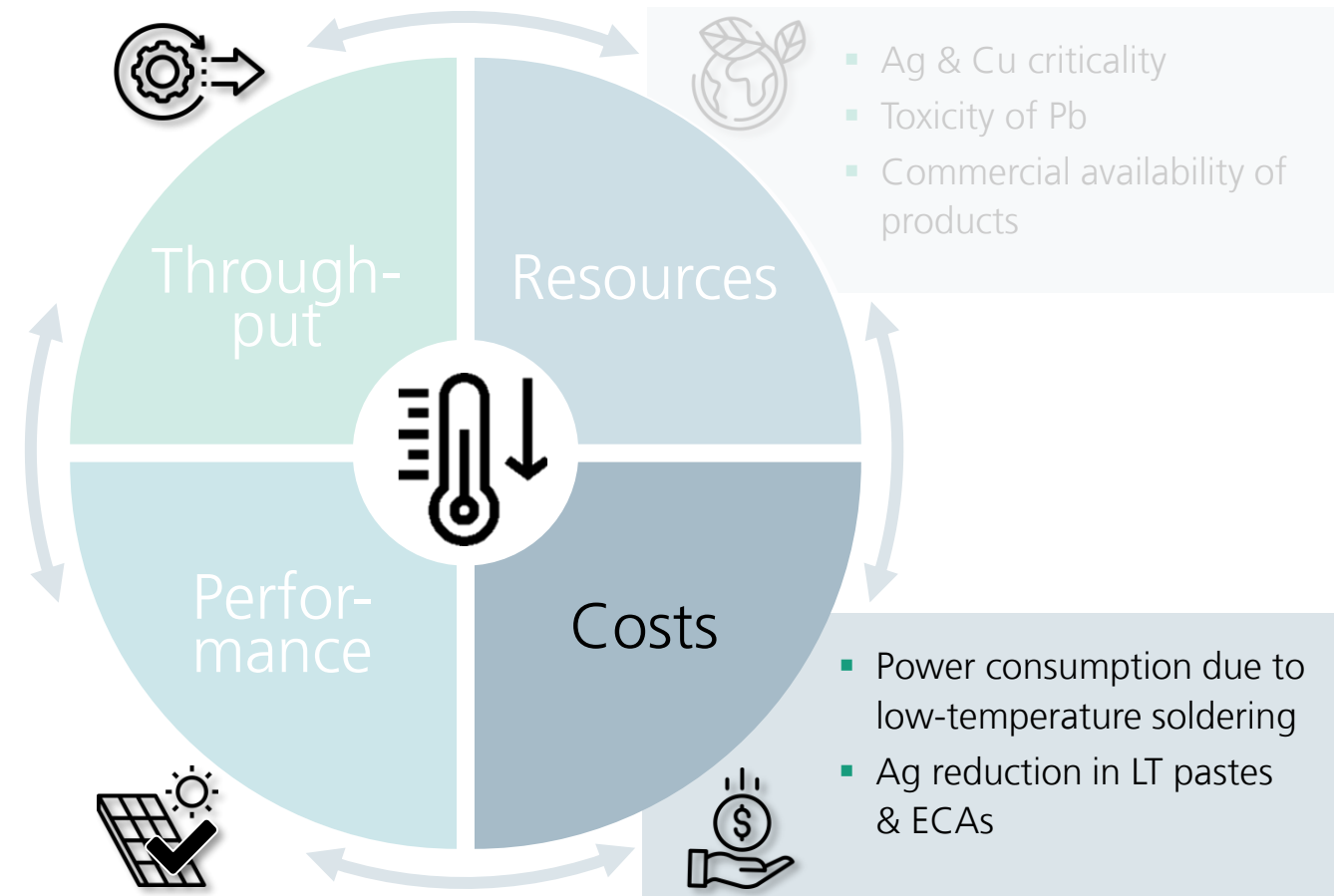
*Ag content in ECAs: 30 %_{wt.} – 70 %_{wt.} **Ag content in LT pastes: 90 %_{wt.} – 94 %_{wt.}

5 [1] Y. Zhang *et al.*, Design considerations for multi-TW scale manufacturing, 2021, DOI: 10.1039/D1EE01814K
[2] RoHS-Richtlinie 2011/65/EU: Beschränkung der Verwendung best. gefährlicher Stoffe in Elektro-/Elektronikgeräten
[3] E. Gervais *et al.*, Raw material needs for the large-scale deployment of PV, 2021, DOI: 10.1016/j.rser.2020.110589

[4] H. Baker, Alloy Phase Diagrams: ASM Handbook
[5] DERA and GBR, Preismonitor Semptember 2022
[6] J. R. Rumble, CRC handbook of chemistry & physics, 2017
[7] D. C. Adriano, Trace elements in terrestrial environments: Biogeochemistry, bioavailability, and risks of metals, Springer, 2001

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Challenges for industrial application



Ag reduction for LT processing

Ag in screen-printed LT pastes

Busbar layout for metallization

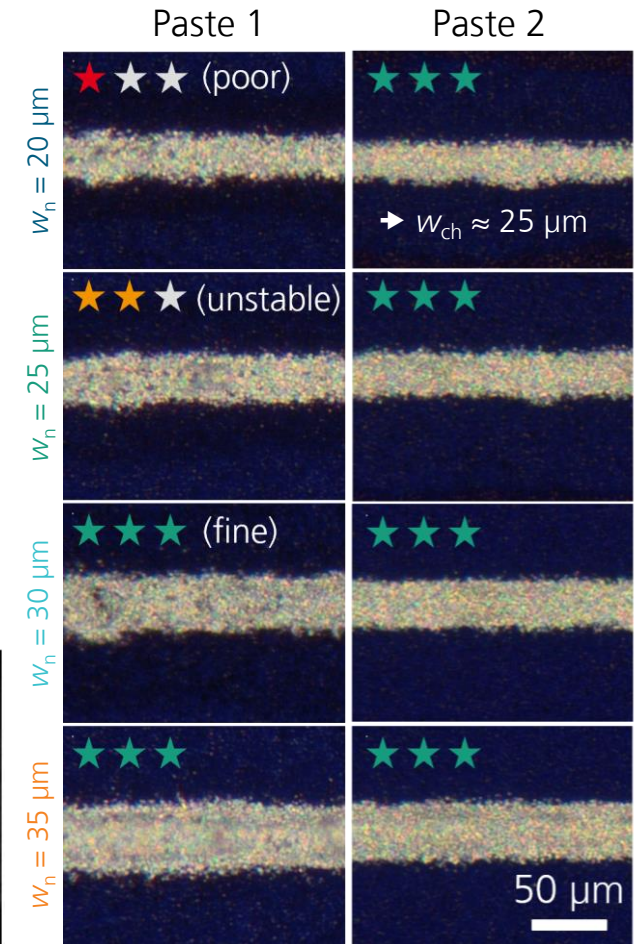
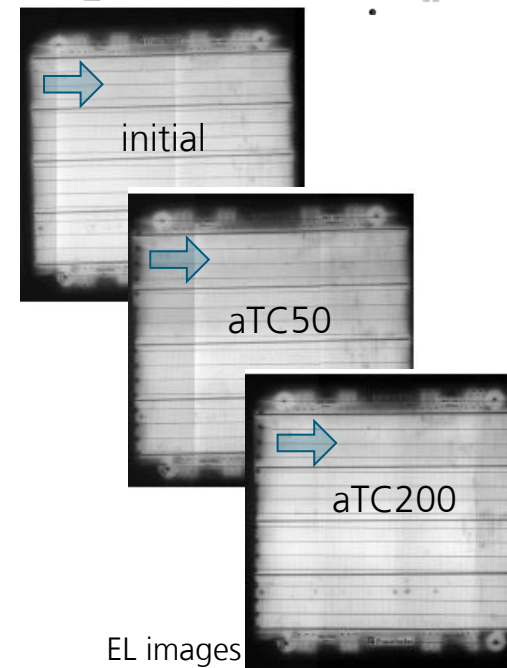
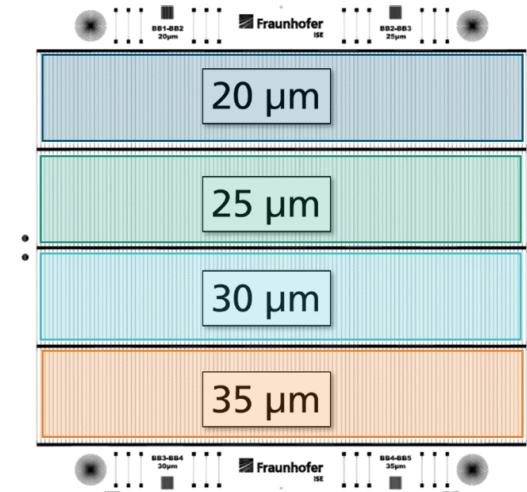
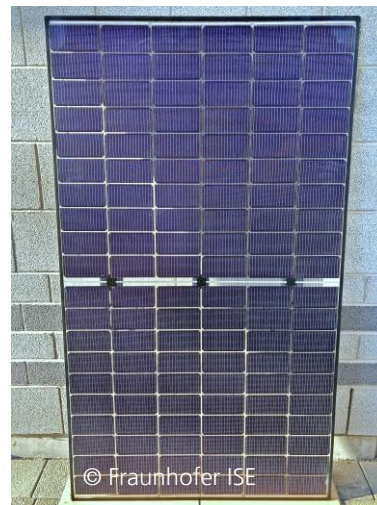
- High Ag consumption for cells with busbars
 - For 5BB M2 SHJ: ~200-300 mg/cell [1,2]

Approaches for Ag reduction

- Substitution of Ag by Cu/Ag pastes [3], increased flooding & printing speed [3], BB-less layouts
- Optimized fine line printing [4]
 - aTC-stable LT fine line fingers with $w_{ch} \approx 25 \mu\text{m}$ width on SHJ bottom cells
 - ➔ -43 % Ag reduction

Transfer to perovskite silicon tandem

- Prototype-module (~1.8 m²) with wire interconnection achieving $P_{mpp} > 400 \text{ W}$



Ag reduction for LT processing

Ag in ECAs for interconnection

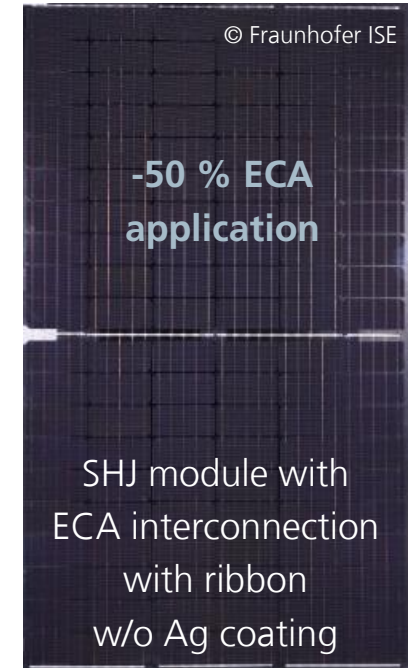
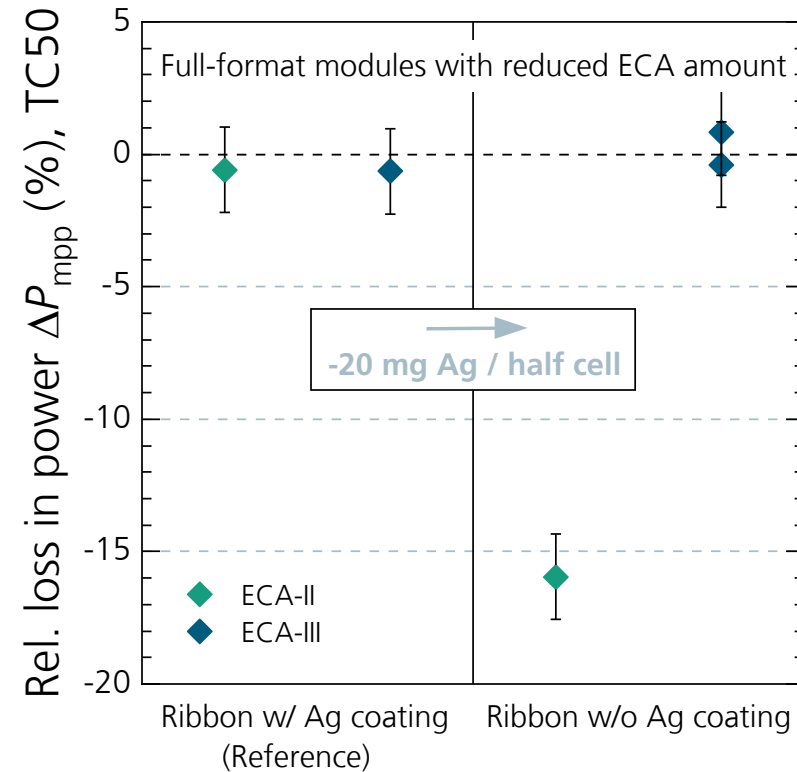
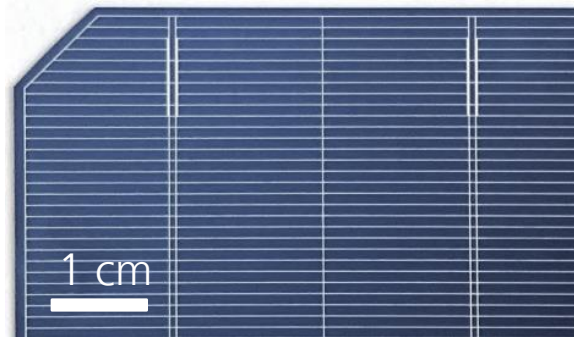


Busbar layout for ECA interconnection

- High Ag consumption for ECA-printing on busbars
 - For 5BB M2 SHJ: ~80-150 mg/cell [1],
~40 mg/cell Ag-coating of Cu ribbon [2]

Approaches for Ag reduction

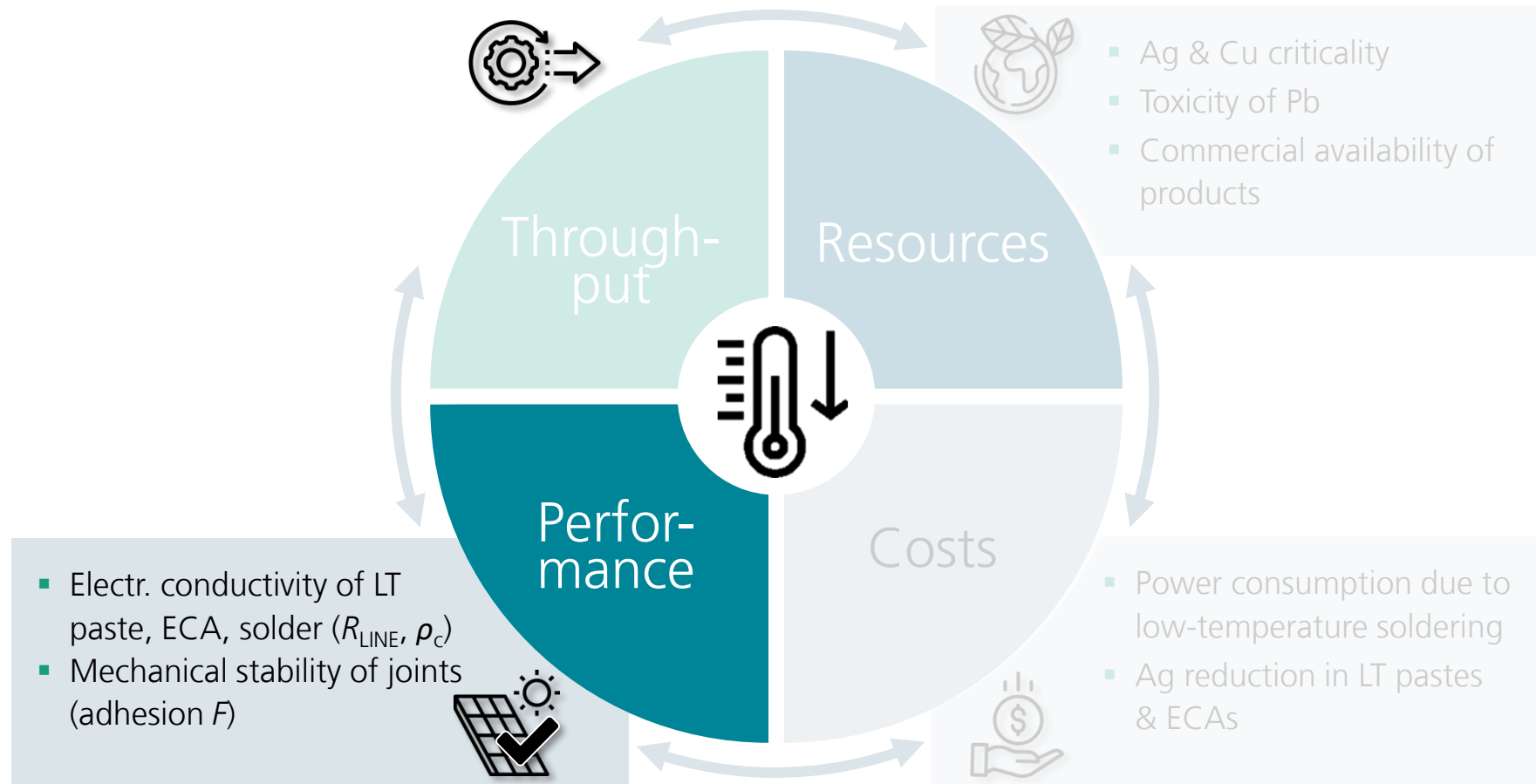
- Printed patterns instead of continuous application [1]
- ECA-free interconnection for shingling [3]
- Optimized BB layout for ECA interconnection
- Using ribbons w/o Ag coating



➔ Compatibility of ribbon & ECA is important

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Performance of LT materials

Mechanical stability

Peel force after interconnection

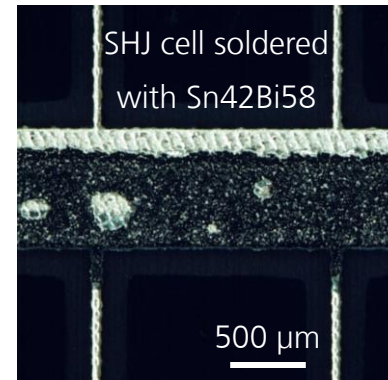
- Stable soldered & glued joints on SHJ solar cells
 - Peel forces in range 0.4 N/mm – 1.2 N/mm [1,2]
- Several soldered SHJ modules on the market passing TC [3]

Challenges for LT soldering

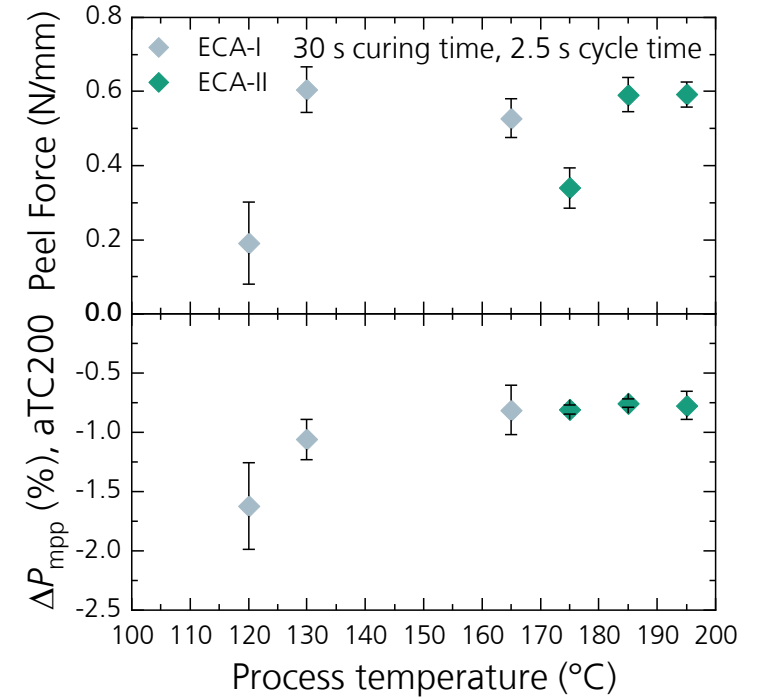
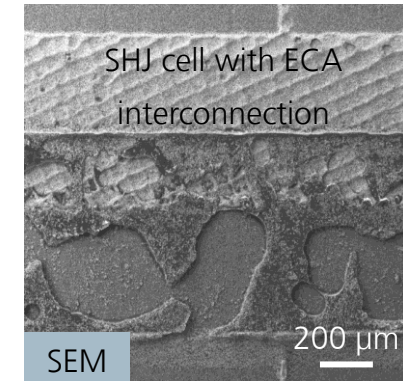
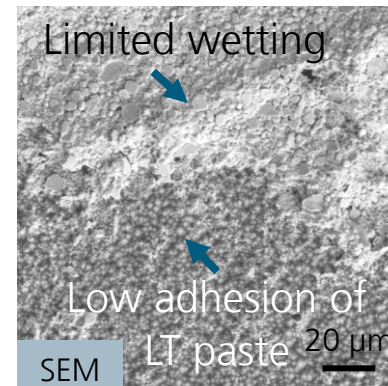
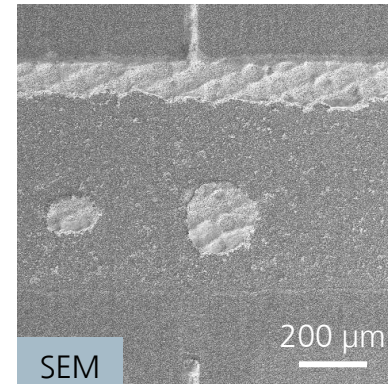
- Wetting of busbar/pad
- Interface between LT paste and wafer
 - Limits adhesion after soldering, dep. on LT paste [1,4]

Challenges for gluing

- Reduction of ECA amount w/o increase of R_s
- Stable joints for low curing temperatures
 - Epoxy-based ECAs available for processing $< 150\text{ }^\circ\text{C}$ for perovskite Si tandem solar cells

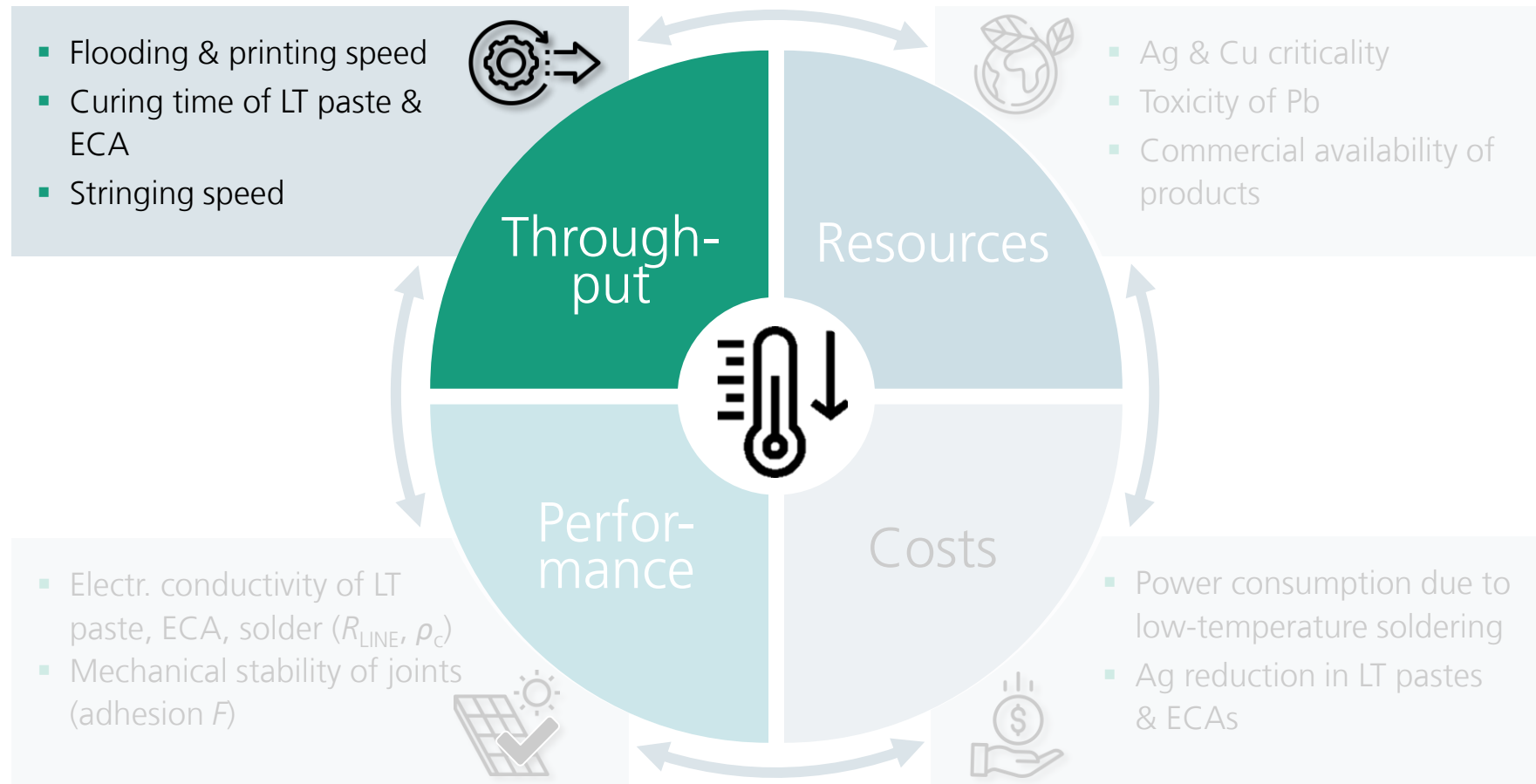


Top view
microscopy



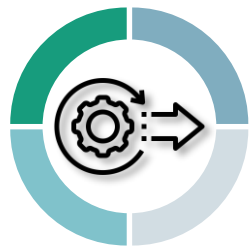
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Throughput during LT processing

Industrially feasible processes

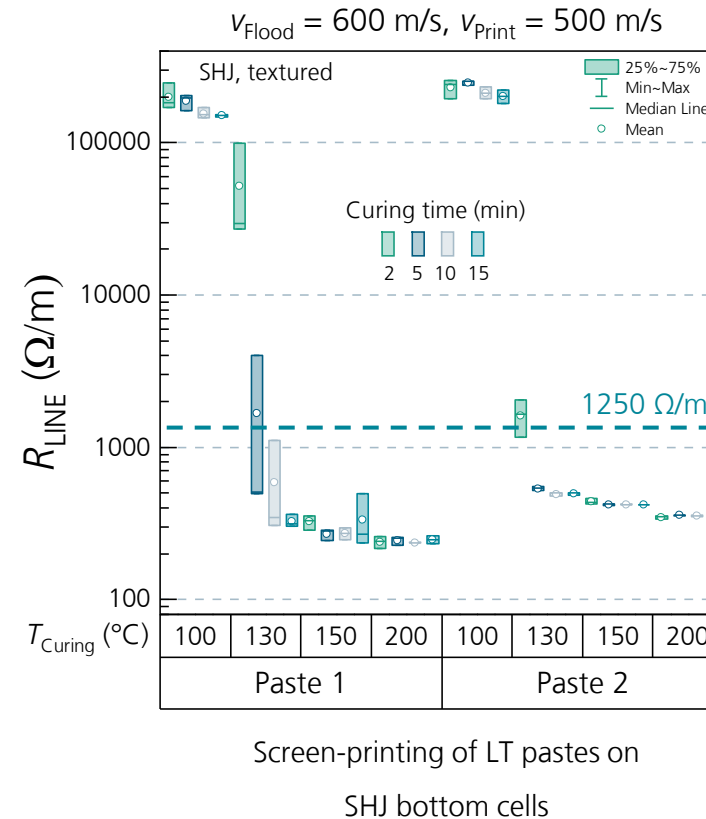


Fast processing of LT pastes

- Increased flooding & printing speed ensuring high conductivity of fingers [1]
- Fast curing of LT pastes resulting in good conductivity
 - $R_{LINE,max}$ for perovskite Si tandem: 1250 Ω/m [2]
 - Paste 2: good conductivity for $T_{Curing} < 150$ °C, fine line printability and fast curing $t_{Curing} = 2$ min

High throughput LT interconnection

- Industrially feasible processes on stringer possible
 - Cycle time < 2 s per solar cell
- Transfer to full-size perovskite Si tandem cells
 - Successful fabrication of soldered full-format tandem modules; adhesion LT paste/wafer remains challenging
 - Numerous perovskite silicon tandem modules (~1.8 m²) manufactured with ECAs, achieving $P_{mpp} > 400$ W [3]

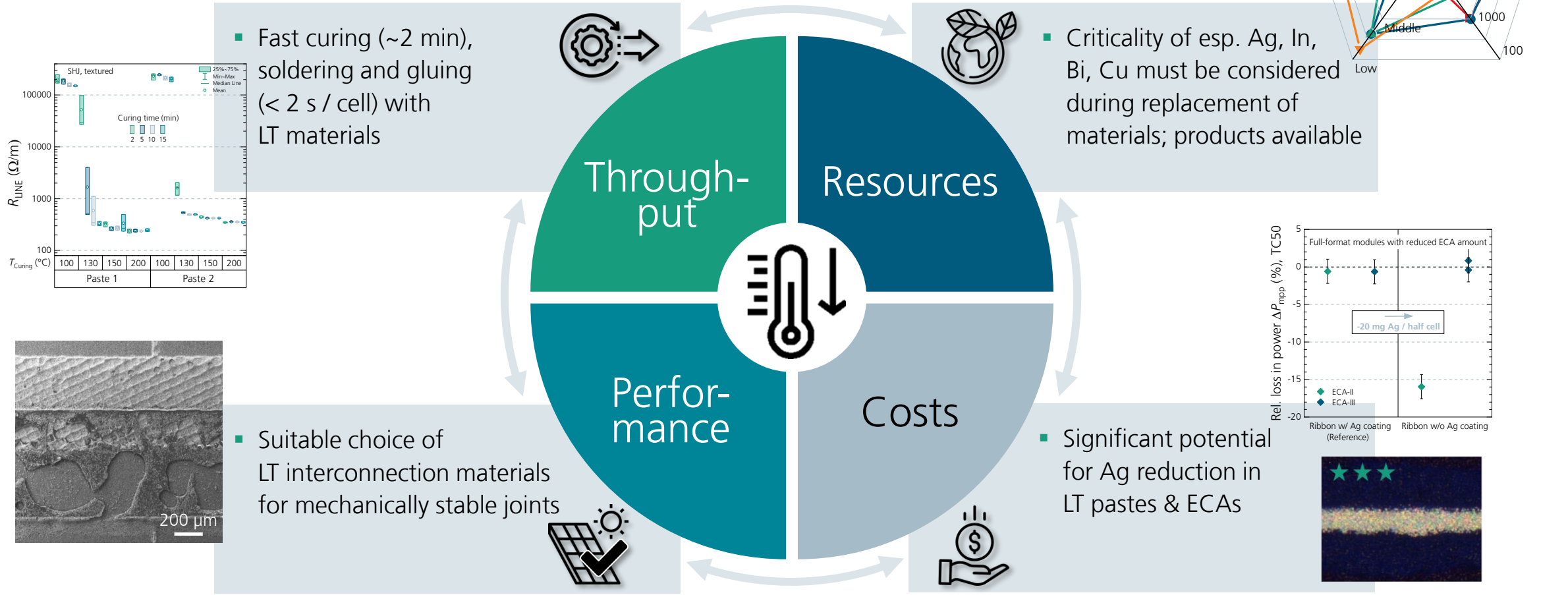


3BB perovskite silicon tandem module with ECA interconnection^[3]



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Take-away messages



Thank you for your attention!

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This work has been funded by the Federal Ministry for Economic Affairs and Climate Action within the projects "HJT 4.0" (contract no. 0324172B), "Smart" (contract no. 03EE1045B) and "SWiTch" (contract no. 03EE1067C).



Supported by:



**Federal Ministry
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**on the basis of a decision
by the German Bundestag**